

MK MOBILE LABS



METAL-FREE CLEANROOMS IN A CONTAINER

- » MOBILE
- » FLEXIBLE
- » ADAPTABLE
- » RAPID DEPLOYMENT



METAL-FREE CLEANROOM TECHNOLOGY



Further Information or questions?

Give us a call or send us an email.
We will be happy to advise you. Reach your contact on:



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METAL-FREE CLEANROOM TECHNOLOGY

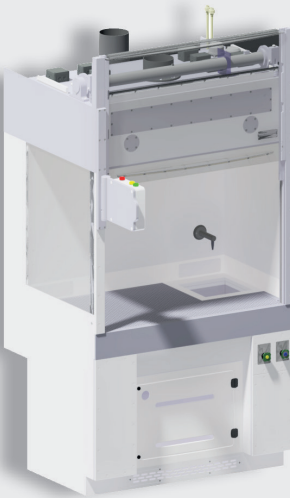
to meet your individual requirements

WETBENCH



- An ideal solution for use in the semiconductor industry
- Cleaning of substrates and equipment
- Non corrosive wet chemical etching (laminar flow)
- HEPA filter directly on the working chamber

WORK STATION VERTICAL



- Cleaning of lab glass
- Avoidance of cross contamination
- Preparing samples for mass spectroscopic analyses
- Laminar flow
- HEPA filter directly on the working chamber

ISOLATOR VERTICAL



- RABS (Restricted Access Barrier System)
- Tight-closing
- Glove ports
- Connecting link through pass-through
- HEPA filter directly on the working chamber

COMBINATION STATION VERTICAL



- Processing and evaporation of samples
- Two different chambers in one station
- Laminar flow
- HEPA filter directly on the working chamber

EXHAUST VERTICAL



- Metal-free fume hood
- Avoidance of corrosion and cross contamination
- Etching processes
- No laminar flow, only exhaust

WORK STATION HORIZONTAL



- Processing and evaporation of samples
- Horizontal air flow
- Position of the hotplates can be changed as needed.
- HEPA filter directly on the working chamber